The antisporozoite vaccine used in the Maryland trials was produced by Hoffmann-La Roche based on work done by a research team headed by Ruth and Victor Nussenzweig at New York University Medical Center. Prospects for manufacture of the vaccine were clouded for a period (Science, 4 February 1983, p. 467). The World Health Organization objected, expressing misgivings about patent rights, when Genentech, a biotechnology firm in South San Francisco, expressed interest in gaining an exclusive license to produce the vaccine. Hoffmann-La Roche subsequently obtained a license as a prospective manufacturer of the vaccine and AIDS sources say that an agreement was made providing for preferential pricing of the vaccine for both AIDS and WHO that both organizations find satisfactory.

If field trials of a vaccine aimed at falciparum sporozoites are successful, a further phase aimed at developing the vaccine as a public health tool would be necessary.

Chip Makers Plan Research Center

Leaders of the U.S. semiconductor industry announced on 5 March that they will invest jointly in a major new center to improve their manufacturing skills and make their products more competitive.

They have not fixed the cost of the project, to be known as “Sematech,” an acronym for Semiconductor Manufacturing Technology Institute. If it adheres to the recommendations made by a recent Defense Department inquiry (Science, 15 August 1986, p. 712), the cost will be over $1 billion, perhaps $2 billion. Although all member companies will contribute, a spokesman for the Semiconductor Industry Association said, a major share will have to come from the federal government.

Charles E. Sporck, president of the National Semiconductor Corporation, formally unveiled the plan in Washington last week. His announcement came after a long and intense debate within the industry over what should be done to make U.S. companies more competitive. It is a sign of independence, Sporck said, that the companies have not come to Washington seeking help until now.

The internal debate focused on what should be put in the new facility. Some smaller companies wanted to install a high-volume production line at Sematech and get International Business Machines to promise to use its output. IBM reportedly declined, although it did agree to contribute a large share toward the new venture. Others wanted to focus on methods for rapidly introducing new designs into production, leaving the manufacturing to be done by individual companies. This view seems to have the upper hand.

Sporck said it will take until June to work out an operating plan. By then, Sematech should have a director, a site, an agenda, clearance from the antitrust division of the Justice Department, and a funding goal. None of these exist now. It is clear, however, that Sematech will focus on production equipment and large-scale manufacturing techniques to make commercial, not military, products.

This move is the latest in a series of steps taken by U.S. silicon chip companies to strengthen their position in the world market, which is eroding rapidly. According to Charles Ferguson of MIT’s Center for Technology, Policy, and Industrial Development, the U.S. companies are headed on a decline that will not be reversed easily. He said in testimony to a Senate subcommittee on 26 February that Japanese efforts on x-ray lithography, “which will probably dominate semiconductor production by the mid-1990s, dwarf those of the United States.” Japanese companies are already on a par with or ahead of U.S. companies in gallium arsenide research, laser systems, and optoelectronics. Unless there is a drastic change in the rate of investment in research and development in the United States, he expects to see “the deterioration of this quintessentially strategic industry.”

JOHN WALSH

Science Policy Programs Progress

The study of the impact of science and technology on public policy took root in academe in the late 1950s and early 1960s. A new survey, “Graduate Education and Career Directions in Science, Engineering and Public Policy,” reports that the field has prospered modestly but still faces some of its original problems.

The survey sponsored by the AAAS Committee on Science, Engineering, and Public Policy focuses on 21 programs that provide professional training. It goes beyond previous inventories by reporting the results of a survey on how alumni of the programs have fared professionally.

Responses from about 550 of the 1500 alumni of the 21 programs show that, for many of them, their graduate training did lead to employment in their field and in jobs that many deem satisfactory. The principal employer from the start has been government, particularly the federal government.

A major hitch is that the alumni of the programs continue to have a professional identity problem. The report notes that there is “no single professional association or journal which might foster linkage among the graduates.” And, so far, the field lacks a common curriculum. Therefore, as the report puts it, the enterprise lacks legitimacy in the academic world and prestige among employers.

As has been true from the start, the programs are divided sharply between those based in social science departments and those in engineering schools or departments. The latter require their students to have technical backgrounds—usually bachelor’s degrees in science or engineering. The social science–based programs generally do not. Curriculum in the engineering-based programs typically stresses a quantitative approach (attempts at scientific methods of policy analysis), while the social science–based programs emphasize the qualitative, case study, approach. In both types of program, the master’s is regarded as a professional degree and the Ph.D. as leading to academic employment or research.

While a few of the programs have gone

*Available from the AAAS Sales Office. $10.
†Institutions with programs in the survey are American University, Boston University, Carnegie-Mellon, Cornell, Dartmouth, Eastern Michigan, George Washington, Georgia Tech, Harvard, Indiana University, MIT, Rensselaer, Stanford, Syracuse, University of Denver, Michigan, Oklahoma, University of Texas at Austin, Vanderbilt, and Washington University.

SCIENCE, VOL. 235
Chip Makers Plan Research Center
ELIOT MARSHALL (March 13, 1987)
Science 235 (4794), 1320a-1320. [doi: 10.1126/science.235.4794.1320a]

Editor's Summary

This copy is for your personal, non-commercial use only.

Article Tools
Visit the online version of this article to access the personalization and article tools:
http://science.sciencemag.org/content/235/4794/1320a.citation

Permissions
Obtain information about reproducing this article:
http://www.sciencemag.org/about/permissions.dtl